

	<b>Hits</b>	<b>Search Text</b>	<b>DBs</b>
2	373	((illuminat\$\$ or expos\$4 or irradiat\$4) same (beam near9 split\$4)) and (mask or reticle or (pattern\$4 near9 structure)) and ((substrate or wafer) near14 (support or hold\$4 or stage)) and ((spatial near14 modulat\$4) or (pluralit\$4 near(mask or pixel)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
3	672	((illuminat\$\$ or expos\$4 or irradiat\$4) same ((beam near9 split\$4) or mirror) same (pluralit\$4 or multiple or two or three)) and (mask or reticle or (pattern\$4 near9 structure)) and ((substrate or wafer) near14 (support or hold\$4 or stage)) and ((spatial near14 modulat\$4) or (pluralit\$4 near(mask or pixel)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
4	87	((illuminat\$\$ or expos\$4 or irradiat\$4) same ((beam near9 split\$4) or mirror) same (pluralit\$4 or multiple or two or three)) and (mask or reticle or (pattern\$4 near9 structure)) and ((substrate or wafer) near14 (support or hold\$4 or stage)) and (((spatial near14 modulat\$4) or (pluralit\$4 near (mask or pixel))) same pattern\$4 same array)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
5	41	((illuminat\$\$ or expos\$4 or irradiat\$4) same ((beam near9 split\$4) or mirror) same (pluralit\$4 or multiple or two or three)) and (mask or reticle or (pattern\$4 near9 structure)) and ((substrate or wafer) near14 (support or hold\$4 or stage)) and (((spatial near14 modulat\$4) or (pluralit\$4 near (mask or pixel))) same pattern\$4 same array) and (project\$4 same magnif\$8)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB